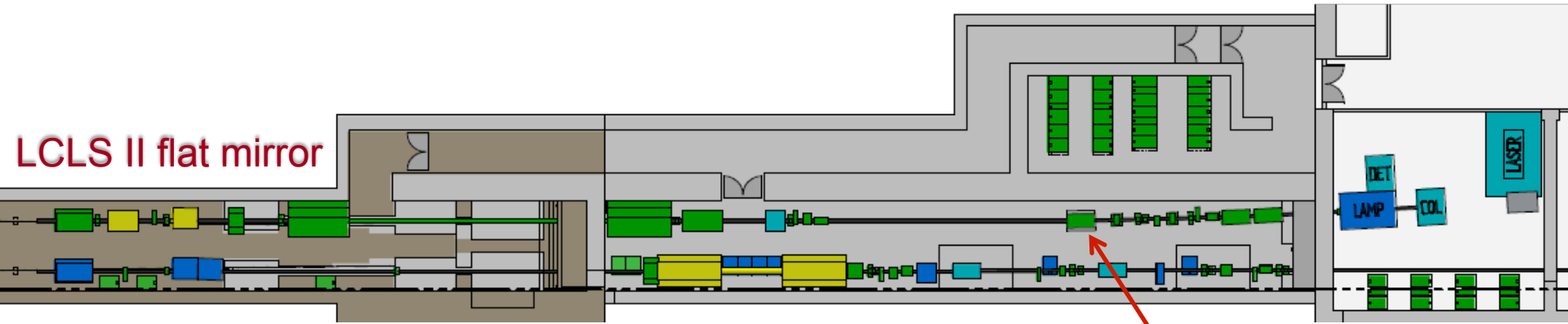


Optics@LCLS

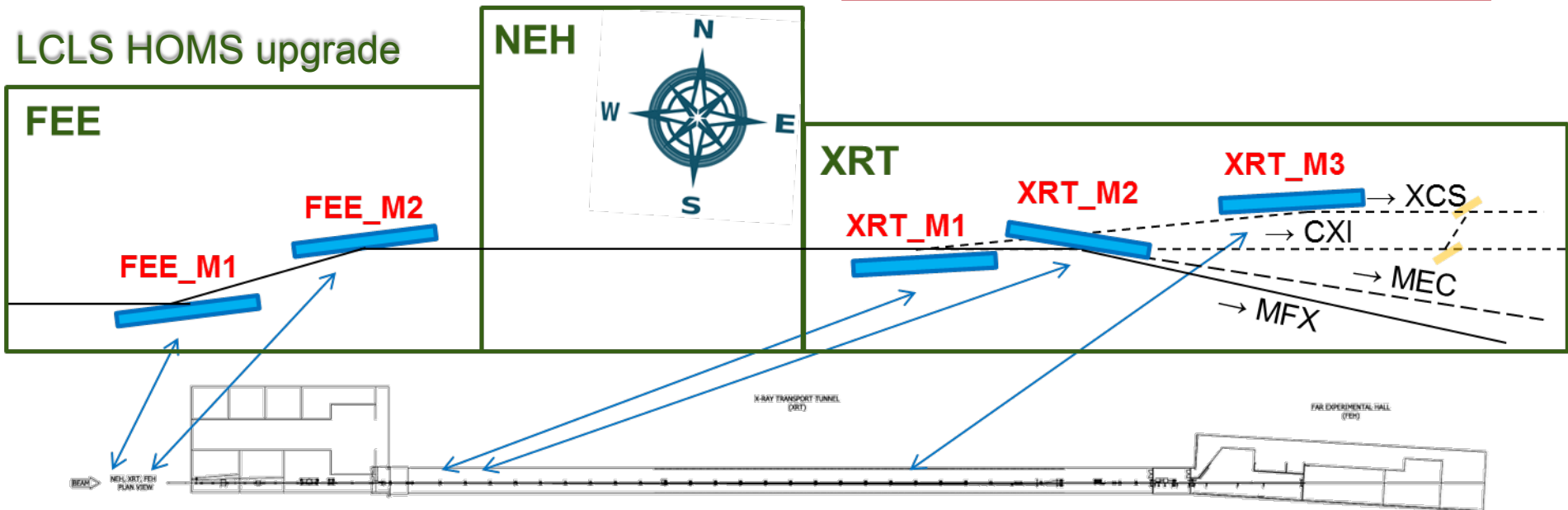
New HOMS *The very big*

NanoX *The very small*

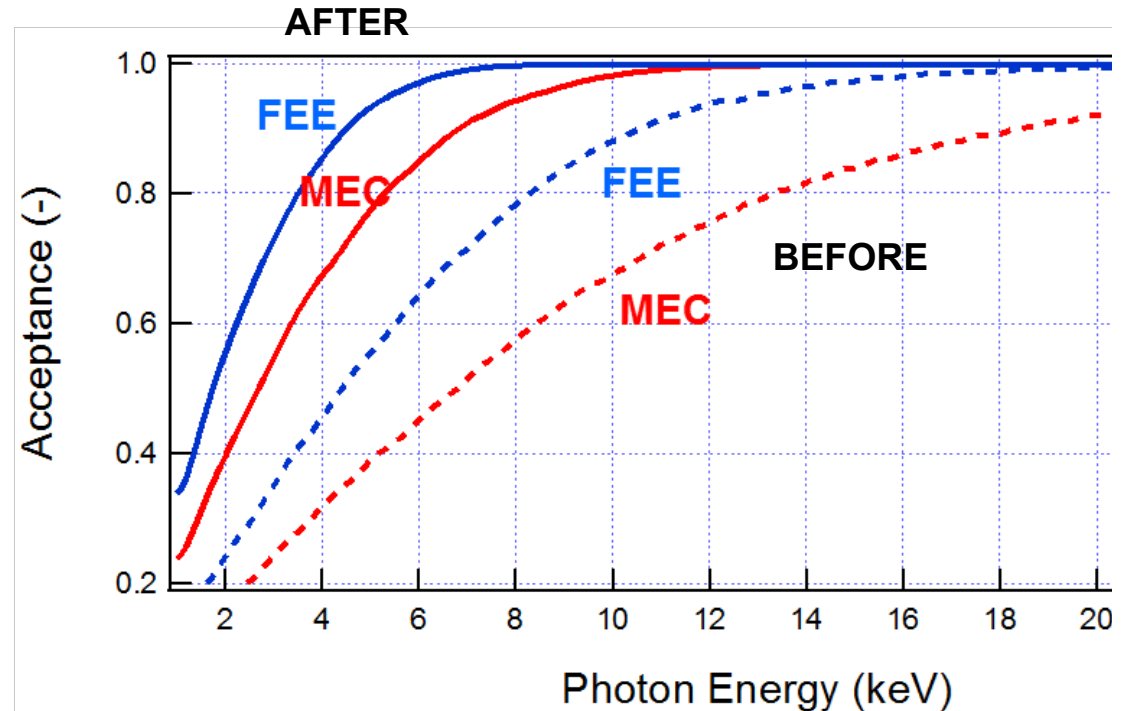
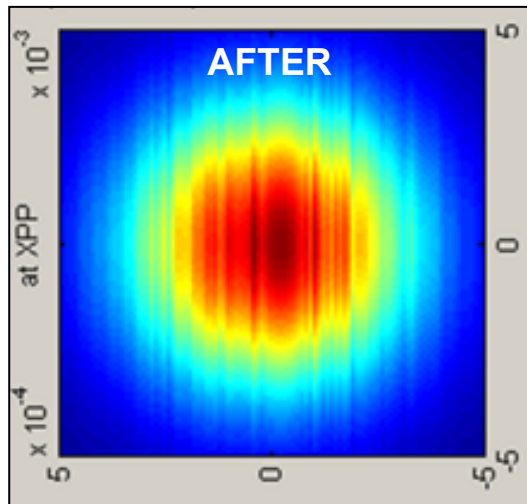
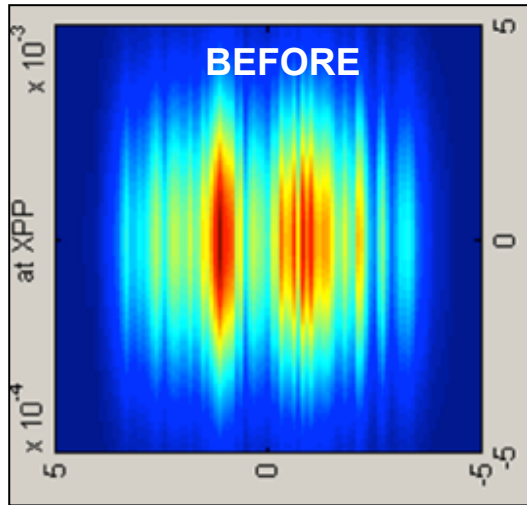
Mirror upgrades for LCLS and LCLS-II



Flat mirror system (12 mrad incidence angle)

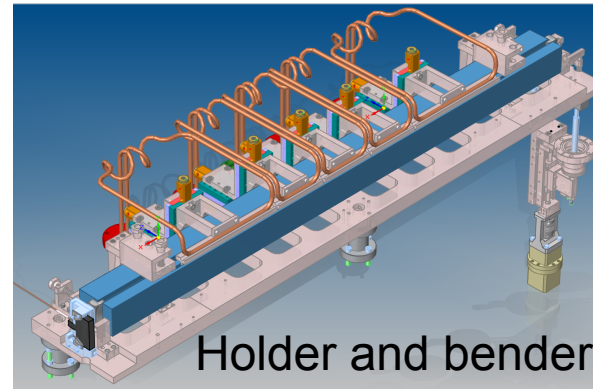
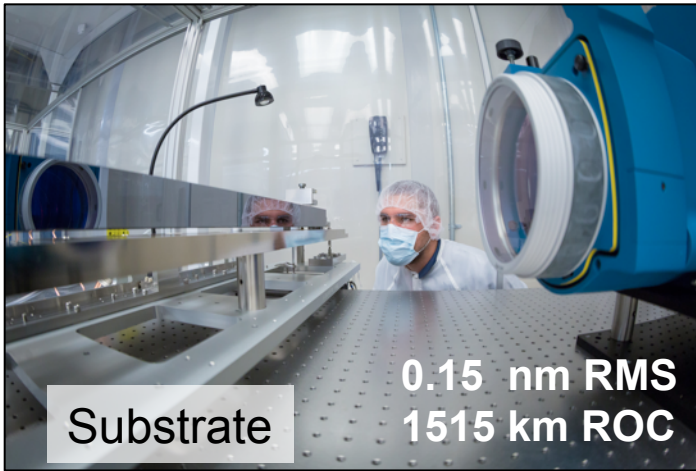


X-ray mirror upgrade motivation

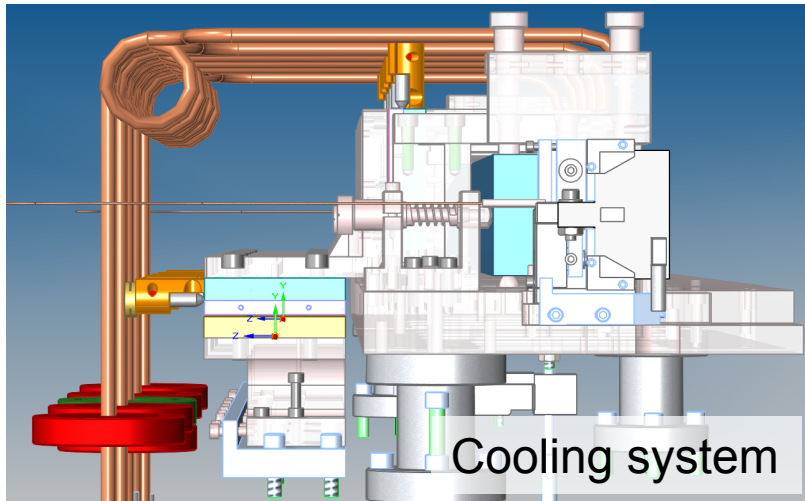


- Substantial improvement in HXR near-field quality & overall beam transport efficiency

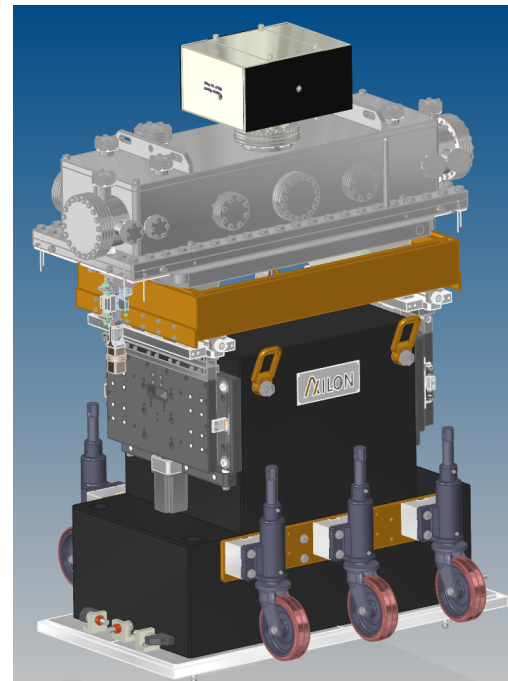
Mirror system overview



**“Distortion Free”
substrate mount**

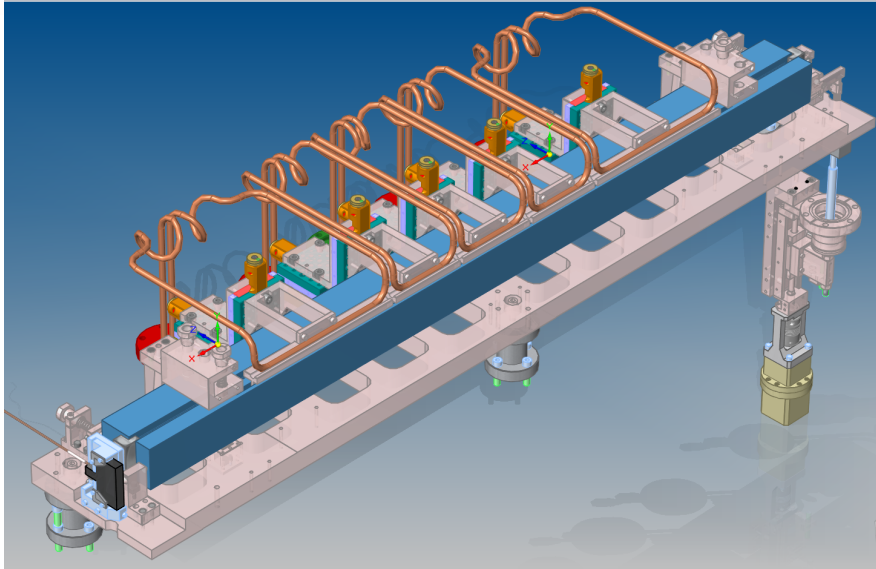


**Multi-circuit cooling system - designed,
assembled and tested in house**

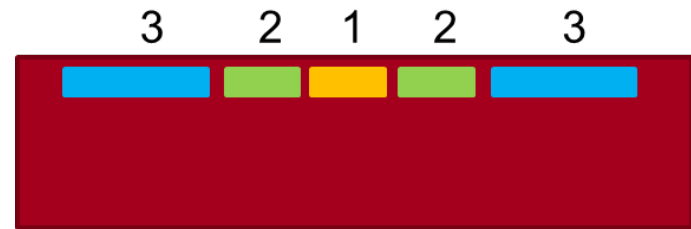


**Vacuum and
high precision
support/motion
system built to
specification by
external vendor**

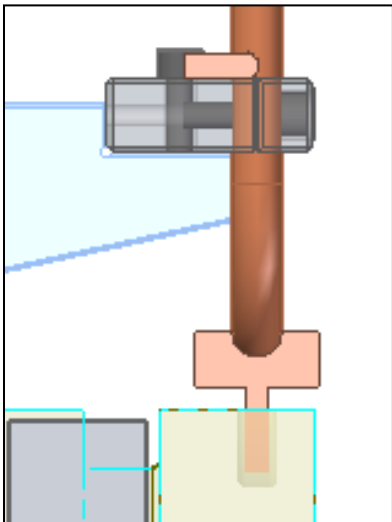
Multi-circuit cooling scheme



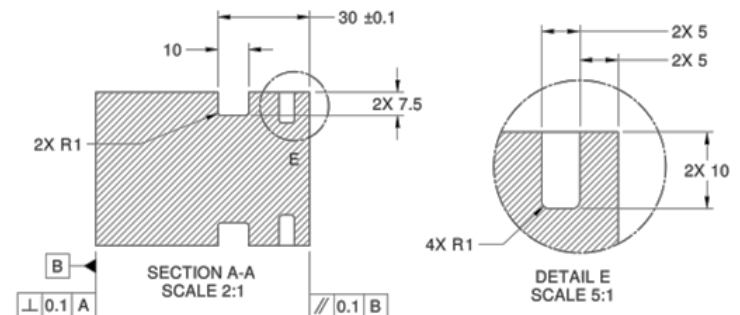
Five cooling circuits (3 lengths) are used to best match the FWHM beam footprint for the full energy range



| Energy Range (eV) | Cooling Footprint (mm) |
|-------------------|------------------------|
| < 400 | 700 |
| ~ 400 – ~ 800 | 300 |
| > 700 | 100 |



The mirror is cooled from one side through a Gallium eutectic filled trough 5 mm from the optic surface. An additional notch is added 20 mm from the surface to minimize the thermal bump and provide mounting features.

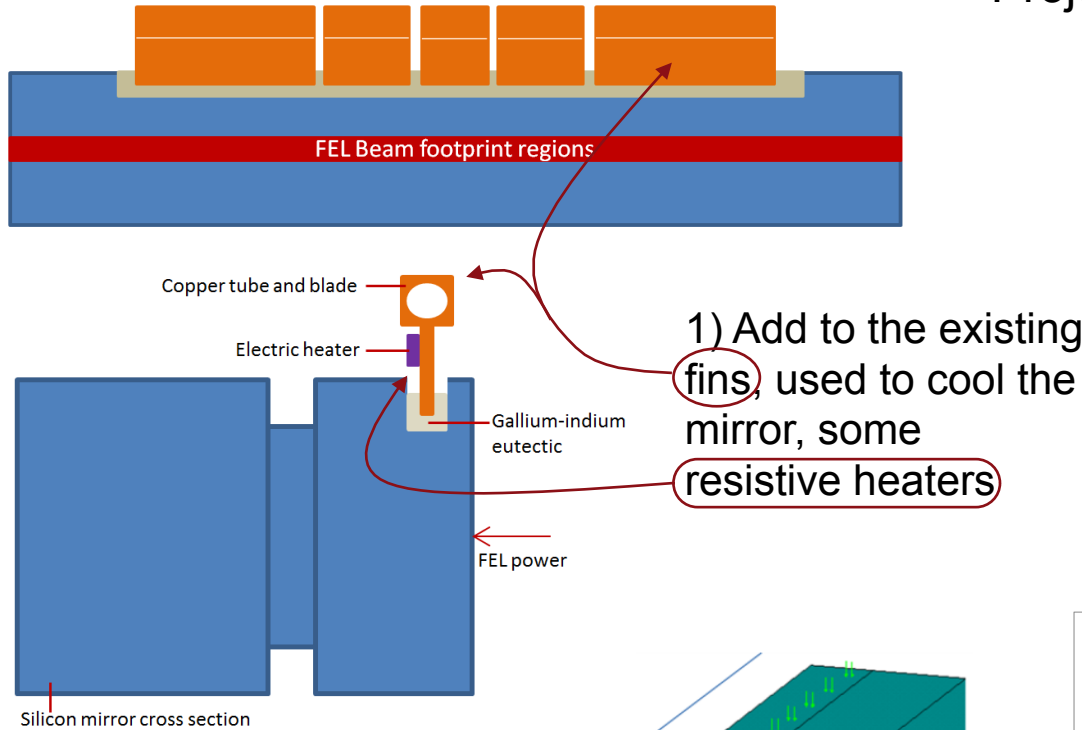


Future development:

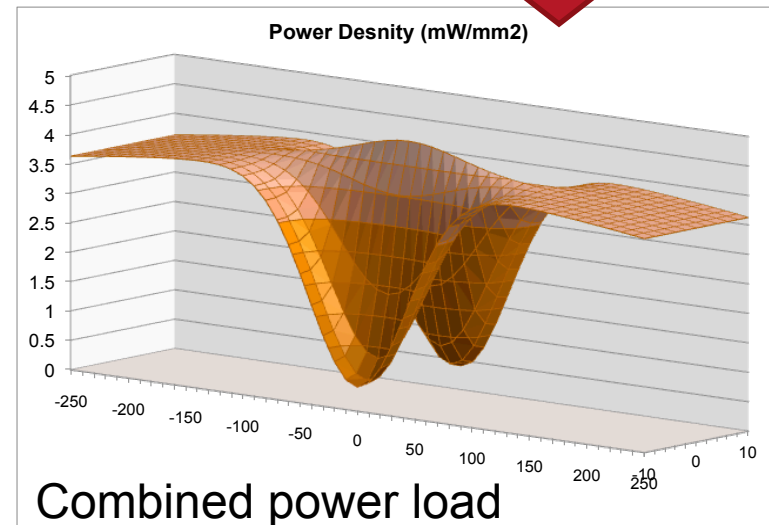
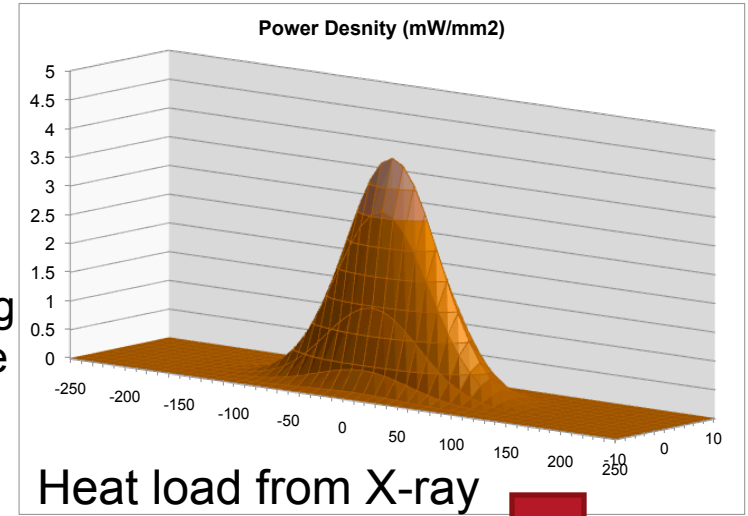
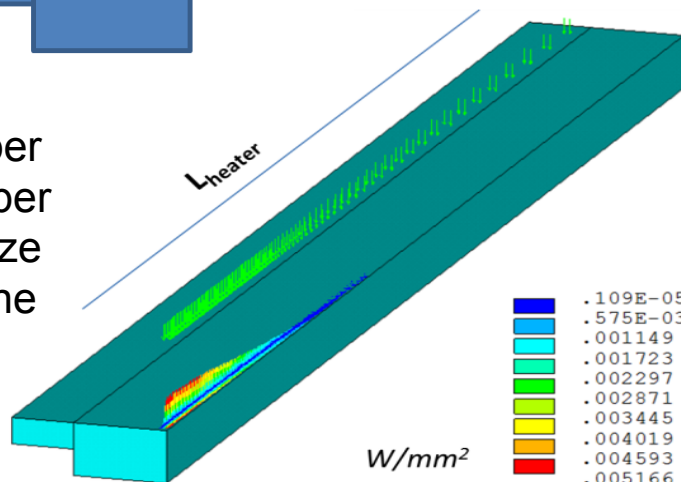
REAL (Resistive Element Adjustable Length) Cooled Optics

SLAC

Project funded by BES over two years

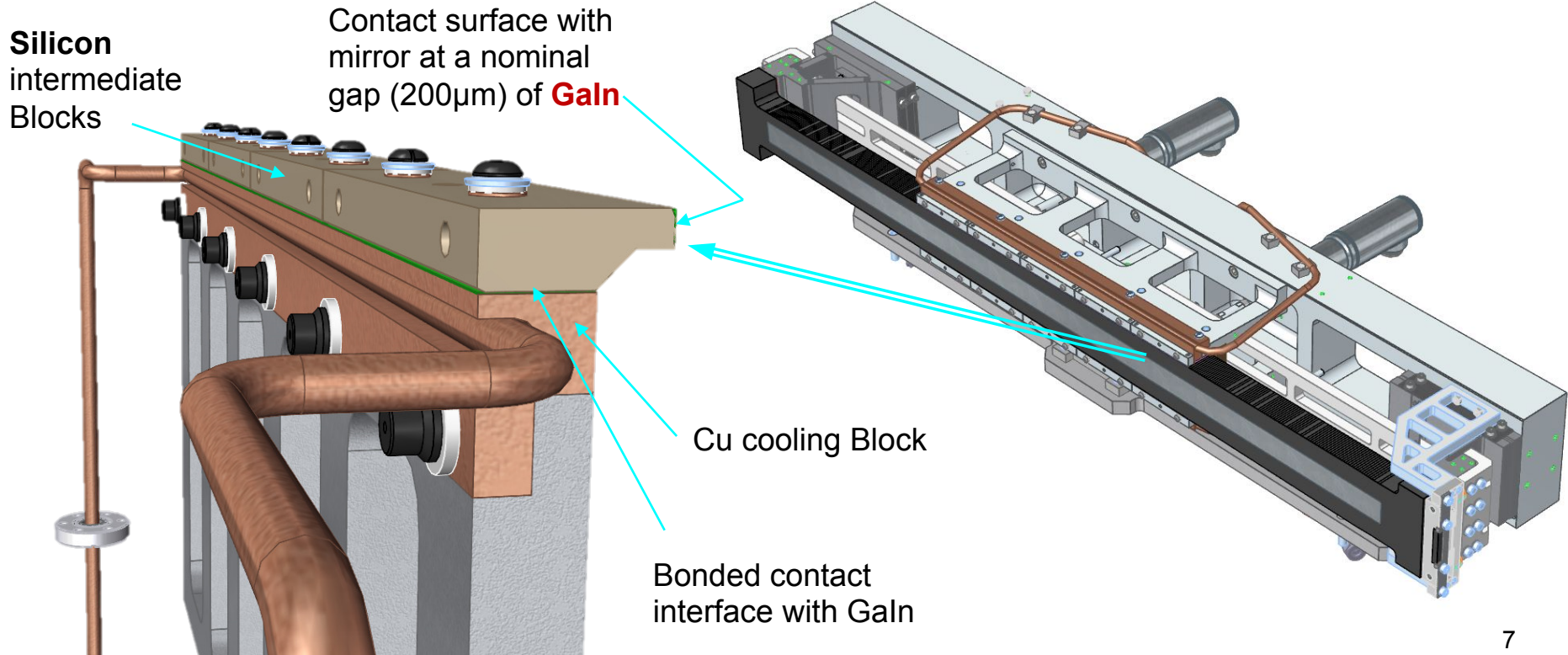
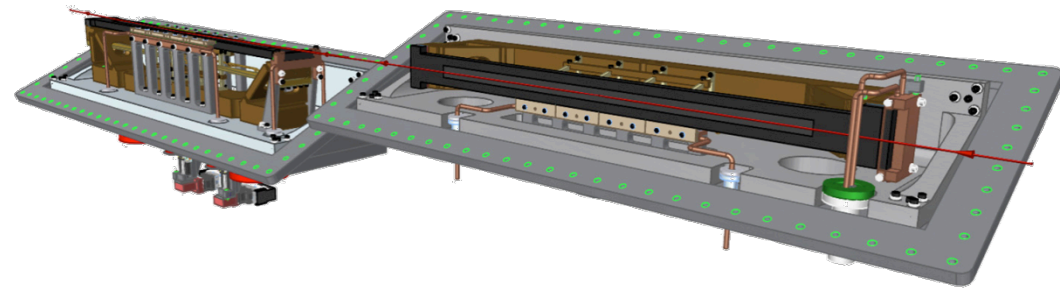


2) Apply the proper power to the proper heaters to equalize deformation on the mirror



Cooled KB mirrors with dynamic bending

- Flexure based optic mount applies unequal moments at the mirror ends to go from flat to the required ellipse(s).
- Substrate is “side-cooled” through Galn interface



Characterizing

FEA results wit

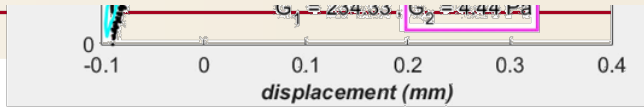
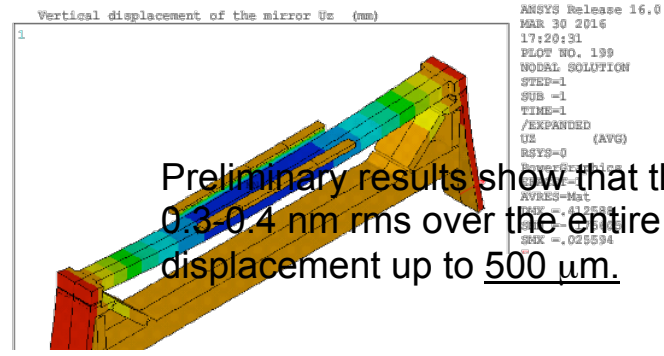
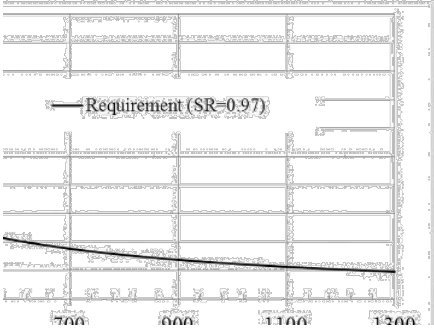
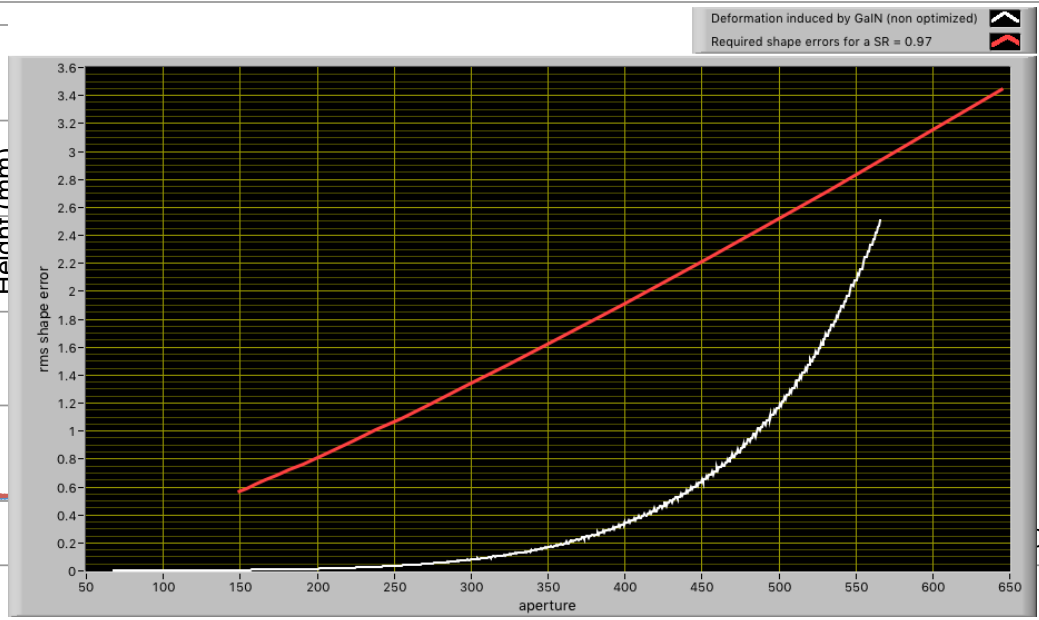
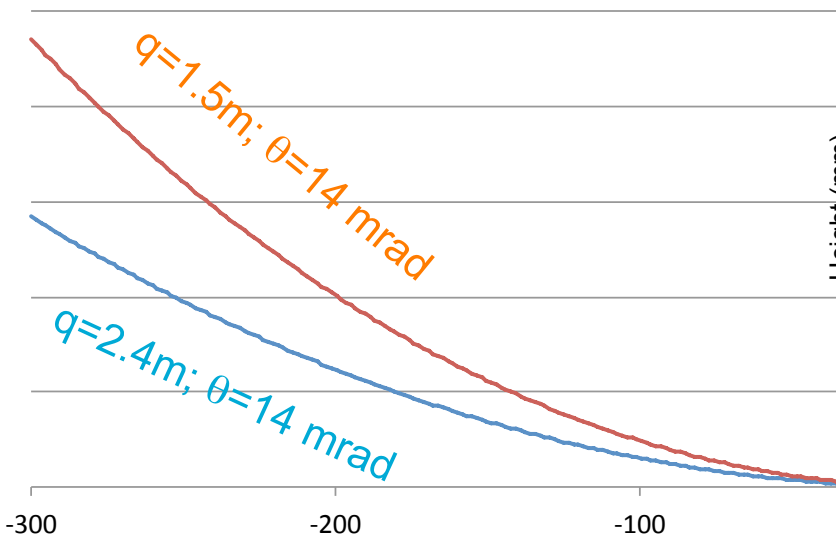
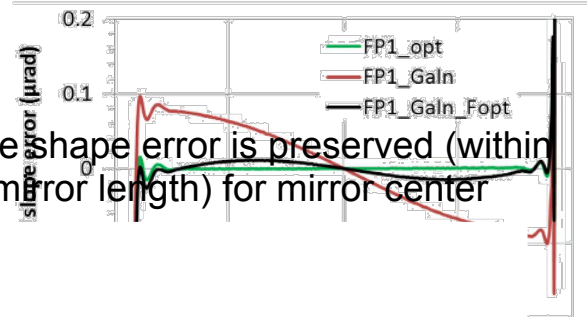


Figure 3



Preliminary results show that the shape error is preserved (within 0.3-0.4 nm rms over the entire mirror length) for mirror center displacement up to 500 μm.

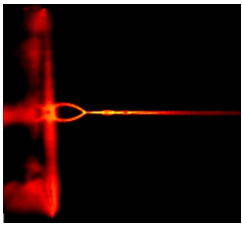
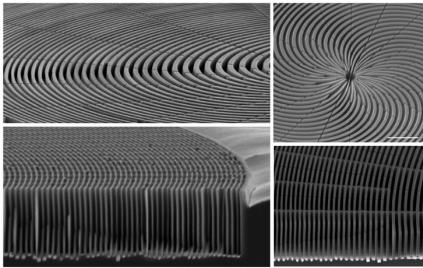


Nano-X for LCLS

Anne Sakdinawat, Georgi Dakovski, Andrew Aquila,
Dan DePonte, Yiping Feng, Don Gardner, Hae Ja Lee,
Yanwei Liu, Bob Nagler, Bill Schlotter, Fan Zhou,
Diling Zhu

Nano-X interfaces broadly with SLAC's science programs

Nano-X draws providing a flexible environment and precision tools for new nanoscience-based solutions to serve the SLAC community.



Nano-X for X-rays

Optics for spatial and temporal control of x-rays, injectors, collimators, beam metrology

Nano-X for Biology

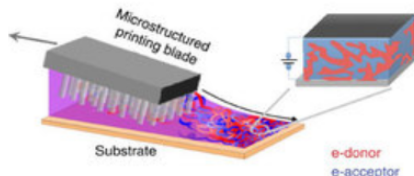
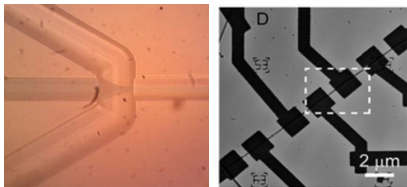
Injectors for single particle imaging, Optics for coherent diffractive imaging, neuroprobes, advanced optics for multi-scale imaging

Nano-X for Chemistry

On-chip *in-situ* and *in-operando* platforms for interface chemistry, advanced spectroscopy at FELs/synchrotrons

Nano-X for Materials

Theory-guided materials and nanosystems fabrication, devices and materials for energy storage and conversion



Nano-X Toolset: Fast, Flexible Nano and Micro Fabrication

The Nano-X Toolset is aimed towards providing SLAC's scientific community with *rapid nano-prototyping* capabilities.

Metallization/Materials

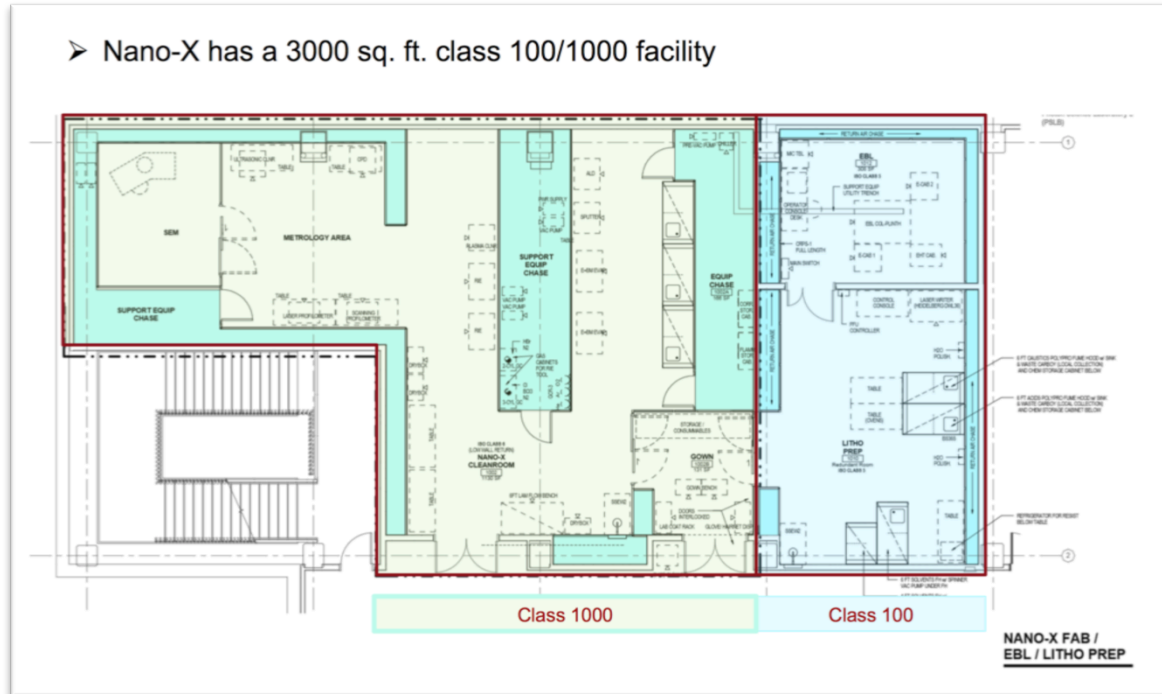
deposition: ebeam evaporation, sputtering, atomic layer deposition, electroplating, electroless plating

Etching: wet etching, reactive ion etching

Metrology: FIB/SEM, visible light microscopy, profilometer, interferometric thin film measurement tools, ellipsometer, AFM/MIM

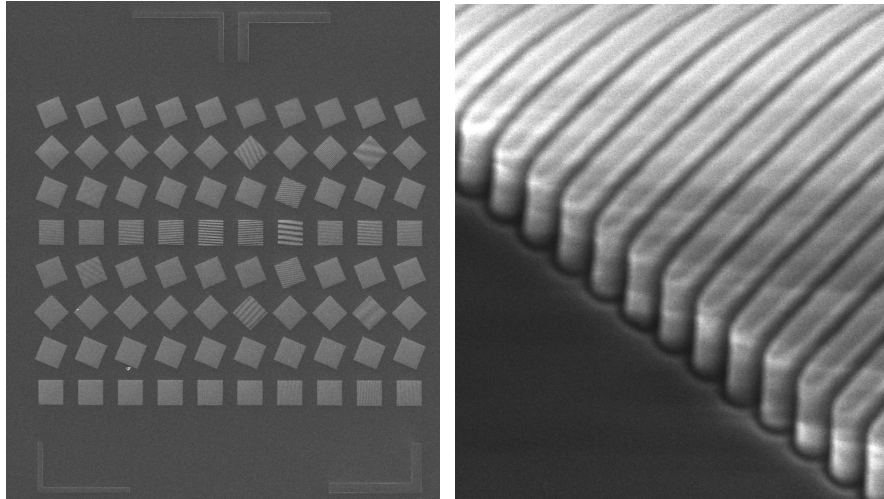
Lithography: direct write electron, ion and photon beam lithography systems, laser cutter, microfluidics printer

➤ Nano-X has a 3000 sq. ft. class 100/1000 facility



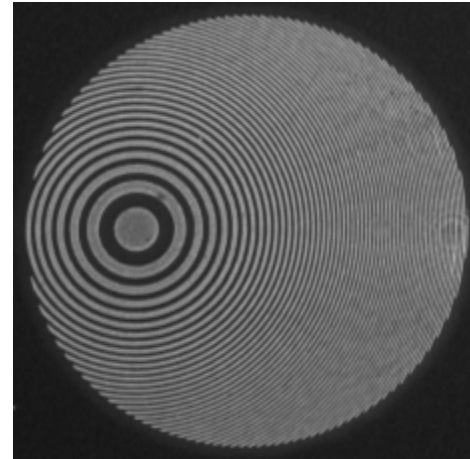
Wavefront Measurement

Ronchi Sensors

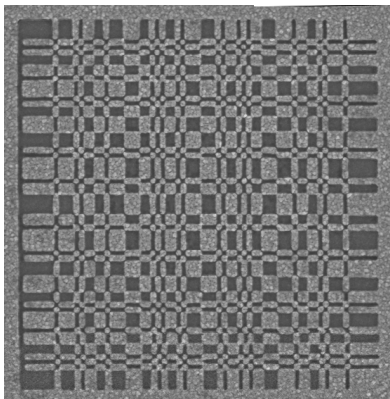


Yanwei Liu, Bob Nagler SLAC

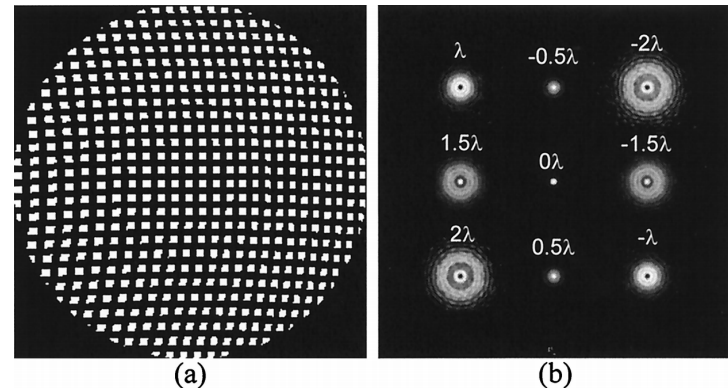
Off-axis zone plate/arrays



Holographic sensors



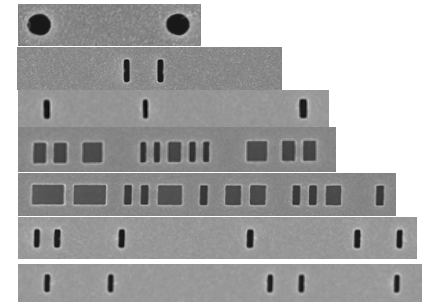
Multi-plane diffractive sensors



What optics and nanostructures will be necessary during LCLS-II instrument commissioning?

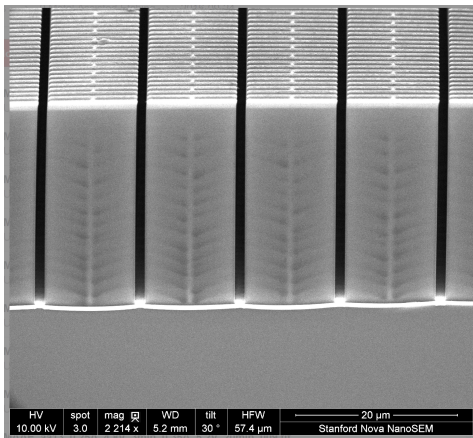
Coherence measurements

- Array of single-shot apertures
 - Pinholes and redundant arrays
- High aspect ratio fabrication methods being explored for high energies as well as reflective



Wavefront measurements

- Toward single-shot wavefront measurement

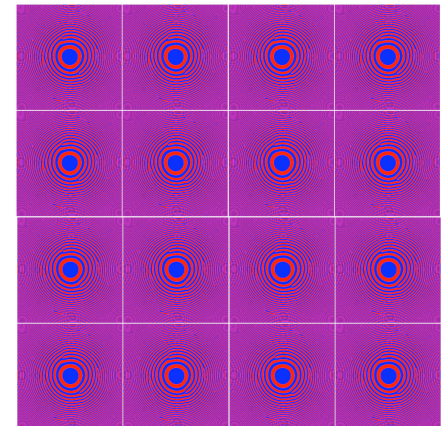


Hartmann sensors

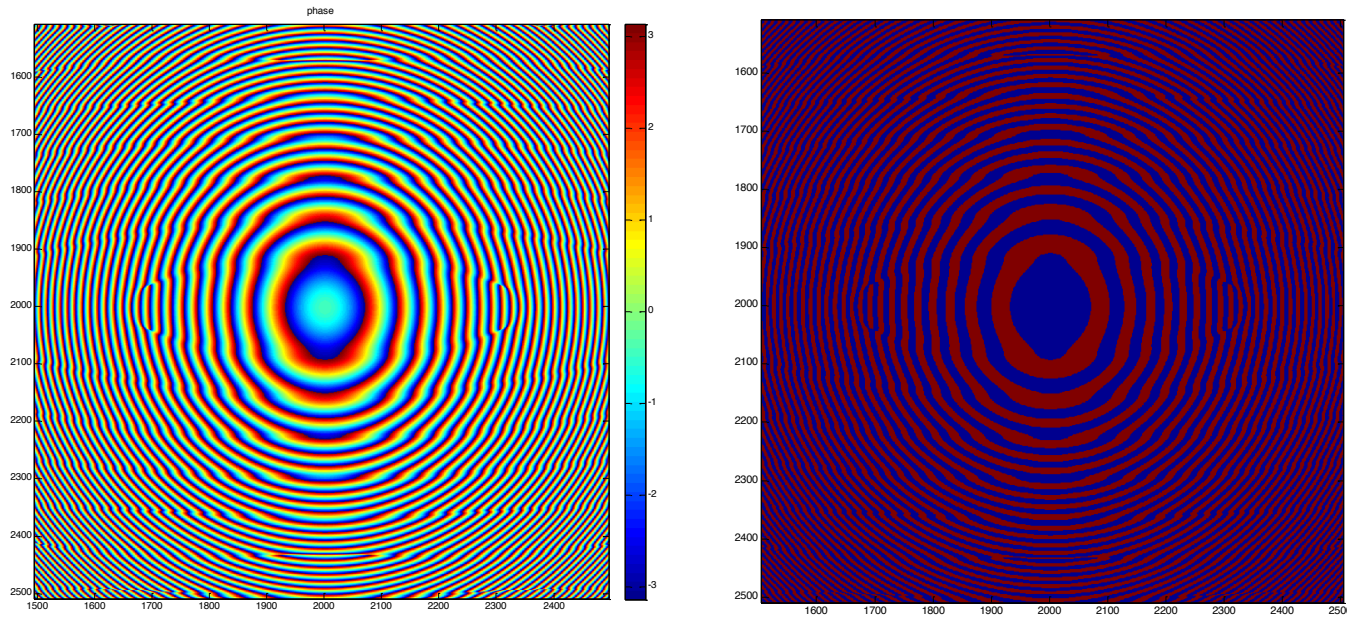
- High aspect ratio for tender and hard x-ray Hartmann sensors being developed

Structured Shack-Hartmann

- Improvement of dynamic range, resolution



Flat-top Beam Shaper for Isochoric Heating of Samples using X-rays

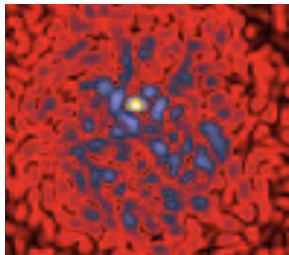
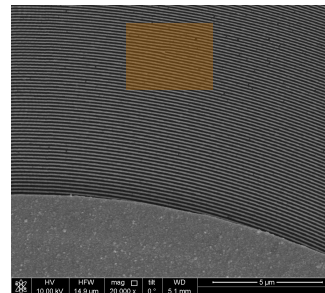
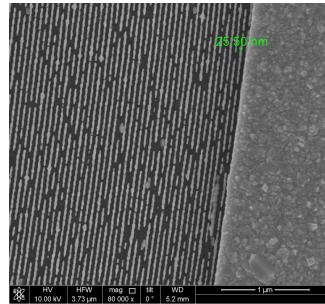
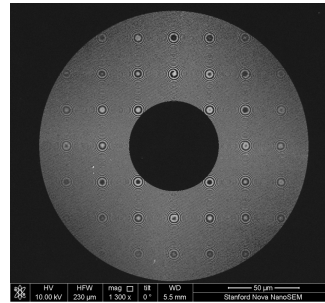
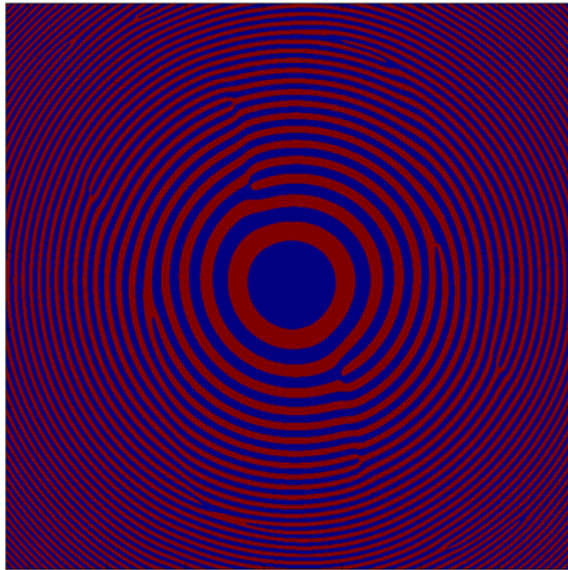


Converts Gaussian beam to Top-Hat beam

Uniform heating of a sample over its volume allows for comparison with theoretical models that assume a single temperature and density throughout the material.

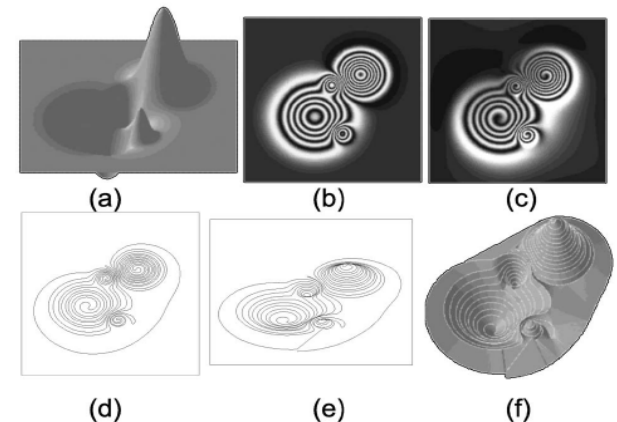
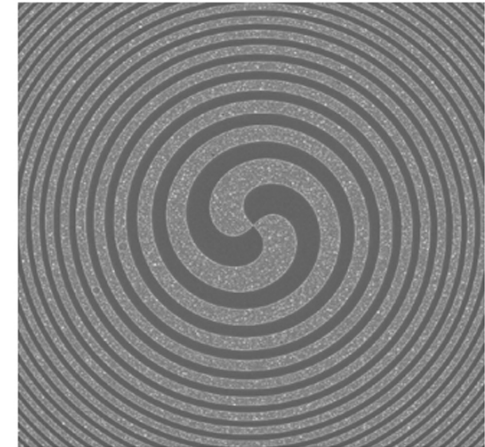
Optics for Imaging and Interferometry

Structured illumination beam shaper for coherent imaging methods



X-ray focal spot @ 800 eV

Spiral Interferometry



Furhapter, et.al. Opt. Lett. 2005

Possible Collaboration Topics

- Diffractive “concentrators” for arrival time diagnostics and spectrometers
- Soft x-ray XAS with diffractive optics
- Diffractive optical elements to generate orbital polarized beams.....diagnostics???
- Wavefront sensor development...invasive and non-invasive.
- *In situ* cleaning methods for optical surfaces

END